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Optics and photonics - Diffractive optics - Vocabulary (ISO/FDIS 15902:2019)

Optik und Photonik - Diffraktive Optik - Begriffe (ISO/FDIS 15902:2019)

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Optique et photonique - Optique diffractive - Vocabulaire (ISO/FDIS 15902:2019)

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Optics and photonics — Diffractive optics — Vocabulary

Optique et photonique — Optique diffractive — Vocabulaire

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Foreword

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For an explanation of the voluntary nature of standards, the meaning of ISO specific terms and expressions related to conformity assessment, as well as information about ISO's adherence to the World Trade Organization (WTO) principles in the Technical Barriers to Trade (TBT), see <u>www.iso</u> .org/iso/foreword.html.

This document was prepared by Technical Committee ISO/TC 172, *Optics and Photonics*, Subcommittee SC 9, *Laser and electro-optical systems*.

This second edition cancels and replaces the first edition (ISO 15902:2004), of which it constitutes a minor revision. It also incorporates the Technical Corrigendum ISO 15902:2004/Cor 1:2005.

The changes compared to the previous edition are as follows:

- in <u>3.3.3.4</u>, an explanation on the factor has been added in a note to entry;
- in <u>3.4.3.4</u>, the sign has been corrected;
- other editorial changes have been made.

Any feedback or questions on this document should be directed to the user's national standards body. A complete listing of these bodies can be found at <u>www.iso.org/members.html</u>.

Introduction

The term diffractive optical element is used for those optical elements which convert an input wavefront to a predetermined output wavefront (or wavefronts) in free space by means of the phenomenon of diffraction. There has been a rapid increase in the use of diffractive optical elements, especially in the field of optical data storage, and they are essential components in optical and electro-optical systems. They are used in a wide variety of applications.

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FINAL DRAFT INTERNATIONAL STANDARD

Optics and photonics — Diffractive optics — Vocabulary

1 Scope

This document defines the basic terms for diffractive optical elements for free space propagation. The purpose of this document is to provide an agreed-upon common terminology that reduces ambiguity and misunderstanding and thereby aid in the development of the field of diffractive optics.

2 Normative references

There are no normative references in this document.

3 Terms and definitions

For the purposes of this document, the following terms and definitions apply.

ISO and IEC maintain terminological databases for use in standardization at the following addresses:

- ISO Online browsing platform: available at http://www.iso.org/obp
- IEC Electropedia: available at <u>http://www.electropedia.org/</u>

3.1 Diffractive optics technologies

3.1.1

diffractive optics

optical technology based on the phenomenon of the diffraction of optical radiation

3.1.2

binary optics

diffractive optics technology whose optical components have a quantized surface structure in height

Note 1 to entry: See <u>3.3.2.8</u> and <u>3.3.2.9</u>.

Note 2 to entry: The word binary originally means a two-step structure in cross section, however, a staircase structure in cross section is usually referred to as binary as well, regardless of the number of the steps. This incorrect wording originates from the fact that these structures are fabricated using a mask lithography technique.

3.1.3

holographic optics

diffractive optics technology that uses holograms as optical elements for transforming an incident wavefront into a specific wavefront or wavefronts

3.2 Diffractive optical elements and their types

3.2.1 diffractive optical element DOE

optical element for which the phenomenon of the diffraction of optical radiation is the operating principle, usually characterized in terms of its periodic spatial structure

3.2.2

amplitude diffractive optical element

optical element which utilizes the diffraction created by its periodic spatial amplitude modulation

3.2.3

phase diffractive optical element

optical element which utilizes the diffraction created by its periodic spatial phase modulation

3.2.4

transmission diffractive optical element

diffractive optical element that operates with transmitted optical radiation

3.2.5

reflection diffractive optical element

diffractive optical element that operates with reflected optical radiation

3.2.6

active diffractive optical element

diffractive optical element whose diffraction characteristics can be dynamically changed

3.2.7

holographic optical element

HOE

diffractive optical element fabricated with an interferometric method

3.2.8

computer-generated diffractive optical element

computer-generated hologram (CGH)

diffractive optical element which is computer-designed and fabricated under computer control

Note 1 to entry: A computer-generated diffractive optical element is generally fabricated using a mechanical method or by lithography, using optical radiation waves (including laser beams), electron beams or ion beams, and is often referred to as a "computer-generated hologram (CGH)".

3.2.9

binary optical element

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BOE https://standards.iteh.ai/catalog/standards/sist/09d39418-b536-4ae2-b274-phase-diffractive optical element having a binary-level or quantized multi-level surface-relief structure

Note 1 to entry: See Note 2 to entry in <u>3.1.2</u>.

3.3 Structure of diffractive optical elements

3.3.1 General structure

3.3.1.1

substrate for diffractive optical elements

basic body of the diffractive optical element

Note 1 to entry: It may support the element's periodic structure on its surface, or it may contain that periodic structure within itself.

3.3.1.2

grating

periodic spatial structure for optical use

3.3.2 Phase structure

3.3.2.1

phase profile

phase distribution of a diffractive optical element, which is added to incident optical radiation

3.3.2.2

surface relief diffractive optical element

optical element whose diffractive property is created by a periodic relief pattern deposited on or corrugated in the substrate

3.3.2.3

Q-factor

Q-value

for a periodic structure with a sinusoidal refractive-index profile, this is given by

$$Q = \frac{2\pi\lambda T}{n_{\rm av}\Lambda^2}$$

Note 1 to entry: The value is used to categorize gratings as either thick or thin. It should be noted that it is defined only for sinusoidal refractive index profile.

3.3.2.4

thin diffractive optical element

diffractive optical element which produces Raman-Nath diffraction

Note 1 to entry: For a diffractive optical element with a sinusoidal refractive index profile, it is characterized by Q < 1.

3.3.2.5

thick diffractive optical element

diffractive optical element which produces Bragg diffraction

Note 1 to entry: For a diffractive optical element with a sinusoidal refractive index profile, it is characterized by Q >> 1.

3.3.2.6

volume phase diffractive optical element ISO 15902:2020

thick diffractive optical element whose diffraction is created by a three-dimensional periodic refractive index distribution within the substrate a88/sist-en-iso-15902-2020

3.3.2.7

phase step stair step step in binary phase structure

3.3.2.8

binary phase structure

discrete phase structure that may have either simple binary or quantized phase steps

Note 1 to entry: See Notes to entry to 3.1.2 and 3.3.2.9.

3.3.2.9

multi-level phase structure

binary phase structure that has more than two phase levels in one period

Note 1 to entry: Multi-level phase structure includes binary phase structure in its definition, however, each term is sometimes used as a synonym of the other.

Note 2 to entry: See Note 2 to entry to <u>3.1.2</u>.

3.3.2.10

blazed diffractive optical element

surface relief diffractive optical element able to concentrate the diffracted light energy in a specified diffraction order or orders using a prismatic structure in one period